AMENDMENTS TO THE CLAIMS

Claims 1-12 were pending prior to the entry of these amendments. Please amend Claims 1, 5, and 9-11.

1. **(Currently Amended)** An optical interference display unit at least comprising:

a first electrode;

a second electrode, in parallel with the first electrode and comprising:

a first material layer; and

a conductive layer on the first material layer; and

a support structure partially covered by the second electrode and supporting **[[**a**]]** an edge of the second electrode;

wherein a material of the conductive layer is more difficult to etch ~~etched~~ than a material of the first material ~~**layer**~~ layer.

2. **(Original)** The optical interference display unit of claim 1, wherein the optical interference display unit is located on a substrate.

3. **(Original)** The optical interference display unit of claim 2, wherein the substrate is a transparent substrate.

4. **(Original)** The optical interference display unit of claim 1, wherein a material of the first electrode is a conductive transparent material.

5. **(Currently Amended)** The optical interference display unit of claim 4, wherein the conductive transparent material is indium tin oxide (ITO), indium zinc oxide (IZO), or indium oxide **[[**(10)**]]** (IO).

6. **(Original)** The optical interference display unit of claim 1, wherein the second electrode is a deformable electrode.

7. **(Original)** The optical interference display unit of claim 1, wherein the second electrode is a movable electrode.

8. **(Original)** The optical interference display unit of claim 1, wherein a material for forming the support structure is selected from a group consisting of positive photoresist, negative photoresist, acrylic resin and epoxy resin.

9. **(Currently Amended)** The optical interference display unit of claim 1, wherein the first material layer is made from a conductive material.

10. **(Currently Amended)** The optical interference display unit of claim 1, wherein the first material layer is made from dielectric material.

11. **(Currently Amended)** The optical interference display unit of claim 9, wherein a material for forming the first material layer is aluminum, chromium, cobalt, copper, silicon nitride or silicon oxide.

12. **(Previously Presented)** The optical interference display unit of claim 1, wherein a material for forming the conductive layer is aluminum, chromium, cobalt, copper, silicon nitride or silicon oxide.

13.-21. **(Canceled)**